



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Lin

Docket No.: 2001 P 14585 US

Serial No.: 10/059,321

Art Unit: 2812

Filed: January 31, 2002

Examiner: Stanetta D. Isaac

Title: Reduction of Negative Bias Temperature Instability in Narrow Width PMOS Using F2 Implantation

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

#14/IOS  
Q.7.001  
7/14/0

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Applicant wishes to bring to the attention of the Patent and Trademark Office the information noted on the enclosed Form PTO/SB/08A which may be considered material to the examination of the above identified application.

This Supplemental Information Disclosure Statement is submitted under 37 C.F.R. §1.97(c) together with a \$180.00 fee under 37 C.F.R. §1.17(p) after the C.F.R. §1.97(b) time period, but before final action or notice of allowance, whichever occurs first.

Please charge the required fee of \$180.00 and any additional amount, or credit any overpayment to Deposit Acct. No 50-1065 of the below mentioned firm.

Respectfully submitted,

6/9/03

Date

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